Chemical control of the charge state of nitrogen-vacancy centers in diamond

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We investigate the effect of surface termination on the charge state of nitrogen-vacancy (NV) centers, which have been ion-implanted a few nanometers below the surface of diamond. We find that, when changing the surface termination from oxygen to hydrogen, previously stable NV− centers convert into NV0 and, subsequently, into an unknown nonfluorescent state. This effect is found to depend strongly on the implantation dose. Simulations of the electronic band structure confirm the disappearance of NV− in the vicinity of the hydrogen-terminated surface. The band bending, which induces a p-type surface conductive layer, leads to a depletion of electrons in the nitrogen-vacancies close to the surface. Therefore, hydrogen surface termination provides a chemical way to control the charge state of nitrogen-vacancy centers in diamond. Furthermore, it opens the way to electrostatic control of the charge state with the use of an external gate electrode.

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Nitrogen-vacancies (NV) in the diamond lattice have been extensively studied in the past for several reasons. NV centers can act as single photon emitters in the visible range with absolute photo stability at room temperature.1 They have found applications in novel fields like quantum computation2 and single-spin magnetometry3,4 due to the possibility to prepare and read out their corresponding spin state optically5 and because of long spin coherence times (T2 = 1.8 ms at room temperature).4 They occur in several charged states, where the neutral (NV0) and the negatively charged (NV−) states are the most common ones. NV− is the prevailing state for centers buried deep in high-purity material. However, it has been observed to become unstable and to turn into NV0 close to the surface of diamonds6 as well as in nanodiamonds.7,8 For applications such as magnetometry, the control of the NV charge state is a crucial point, as defects with reliable spin properties in close vicinity to the surface are required. Therefore, it is of great interest to understand the influence of the surface9 and to gain control over the charge state of the NV centers in diamond.

The properties of diamond surfaces are known to depend strongly on their surface termination. For instance, in an intrinsic, oxygen-terminated diamond, the band gap of 5.45 eV results in a negligible concentration of free charge carriers [Fig. 1(a)]. On the other hand, an accumulation of holes is observed when the diamond surface is hydrogenated.10 The C-H bonds induce an effective surface dipole moment, which shifts the conduction and valence band upward, leading to a negative electron affinity \( \chi \approx -1 \) eV [Fig. 1(b)].11 If the diamond is brought in contact with air, a layer of atmospheric adsorbates will form at its surface. These adsorbates provide energy levels which serve as acceptor states for electrons from the diamond valence band and defects in the band gap. Electrons are transferred into the adsorbate layer until the Fermi level \( E_F \) in the diamond has equilibrated with the electrochemical potential \( \mu \) in the adsorbate layer.12 This leads to a band bending at the diamond surface and the formation of a two-dimensional hole gas in the potential well at the diamond surface [Fig. 1(c)], making it conductive. This effect has been used for the development of different types of field-effect transistors (FETs) (solution-gated FETs,13 ion-sensitive FETs,14 enzyme-modified FETs,15 in-plane gate FETs16), where the number of holes in the surface conductive channel can be modulated over several orders of magnitude with an external gate electrode. The band bending not only leads to accumulation of holes but is also expected to influence the charge state of NV centers. The upward band bending is likely to render the NV centers positively charged, and thus modify their fluorescence properties. In this work, we investigate the effect of the surface termination of diamond on the charge state of NV centers using confocal fluorescence microscopy.

Experiments were conducted on electronic grade, synthetic single-crystalline diamonds with a nitrogen concentration below 5 ppb (purchased from Element Six Ltd.). NV centers were created by focused N ion beam implantation at energies ranging from 1.5 to 30 keV, followed by thermal annealing at 800 °C. The diamond surfaces were thoroughly cleaned in sulfuric acid and oxygen plasma. Samples were fully hydrogen-terminated in a microwave-assisted plasma reactor.17 A grid pattern of photodiode or, alternatively, routed to a spectrometer. Different filter and bandpass combinations were employed to distinguish between NV0 and NV−. It should be noted that the \( z \) resolution of the microscope (≈1 \( \mu \)m) is not high enough to resolve the depth of NV centers, which are implanted within the first 50 nm of the diamond crystal.

The effect of surface termination could be confirmed by investigating the fluorescence of NV− and NV0 in diamonds with different implantation energies, resulting in different
implantation depths, and with varying doses. Figure 2(a) shows a schematic representation of the density of implanted NV centers in the first few nanometers at the diamond surface. It should be noted that higher energies not only lead to a deeper implantation but also to a broader distribution of the NV centers. Figures 2(b) and 2(c) show typical confocal two-dimensional scans across the diamond surface for different implantation energies (10 and 30 keV) but with comparable dose ($1 \times 10^{10} \text{ cm}^{-2}$). The surface termination pattern (O versus H) can be clearly recognized, as single negatively charged NVs are observed in the oxygen-terminated regions, whereas there is very little signal emitted from the H-terminated region. Also, there is no fluorescence from NV$^0$ observed in the H-terminated part. However, the fluorescence could be fully recovered by exposing the H-terminated regions to an oxygen plasma. We therefore conclude that the nitrogen vacancies in this region are neither negatively charged nor neutral but are in an unknown, nonfluorescent state.

In the 10-keV sample, a large implantation spot includes a dose gradient from the center ($\approx 1 \times 10^{13} \text{ cm}^{-2}$) to the edge ($\approx 1 \times 10^{10} \text{ cm}^{-2}$). Figure 3 shows scans taken at the center (high dose), outside the center (medium dose), and at the edge (low dose) of the implantation spot. When comparing different doses at the same implantation energy, we observe that, at very low doses, the contrast between oxygen- and hydrogen-terminated regions is strong. This contrast weakens toward higher doses [Figs. 3(a)–3(c)]. Figure 3(d) shows a more quantitative analysis of the dose dependence. Spectra in the hydrogenated and oxygenated regions are evaluated by fitting the spectrum of single NV$^0$ or NV$^-$ (taken from Rondin et al.$^5$). The dose is inferred from the NV$^-$ population in the oxygen-terminated region, whereas NV$^0$ or NV$^-$ are extracted from the hydrogen-terminated part. It can be seen how the relative amount of NV$^-$ increases from below 10% at low dose to more than 80% at high dose. At the same time, the amount of NV$^0$ decreases only slightly from 30% to below 20%. The remaining NV centers (rest), which do not show fluorescence, are assumed to be positively charged and decrease from more than 60% at low dose to almost 0% in the center of the implantation spot.

In order to get a better understanding of this effect, the band structure of diamond and the charge state of nitrogen-related impurity centers were calculated using the nextnano$^3$ software.$^{18}$ Here, the Poisson equation is discretized on a nonuniform grid using the finite differences method and solved iteratively in a self-consistent manner.$^{18-20}$ In the diamond, the single-band effective mass Schrödinger equation is solved and coupled to the Poisson equation via the charge density as described by the wave functions. The occupation of the subbands and defect levels in the band gap is determined by the

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**Figures and Captions**

**FIG. 1.** (Color online) Energy-band schematic of diamond. (a) O-terminated diamond: The conduction band $E_C$ lies below the vacuum level $E_{\text{vac}}$ (electron affinity $\chi = +1.7 \text{ eV}$). The NV$^-$ level lies beneath the Fermi level $E_F$, where the position is mainly determined by the bulk concentration of nitrogen. (b) H-terminated diamond: The bands are shifted upward by the hydrogen termination ($\chi \approx -1.0 \text{ eV}$). Electrons can transfer into acceptor states $\mu$ of an adsorbed water layer. (c) Equilibrium is established and a two-dimensional hole gas (2-DHG) is induced at the surface. Close to the surface, the strong band bending modifies the occupancy probability of the impurity levels.

**FIG. 2.** (Color online) (a) Schematic of the implantation profile at the diamond surface for energies of 10 and 30 keV. (b), (c) Confocal scans of diamond surfaces showing the fluorescence intensity of single NV$^-$ [650 nm longpass filter (LP)] for implantation spots of different energies (10 and 30 keV). The darker regions correspond to the H-terminated part of the surface. Scale bar is 5 $\mu$m.

**FIG. 3.** (Color online) (a)–(c) Confocal scans of a 10-keV implanted diamond surface showing the fluorescence intensity of NV$^-$ (650 nm LP, 532 nm excitation at 240 $\mu$W) at different implantation doses (low, medium, high, respectively). In (c), dashed lines indicate the O- and H-terminated regions. Scale bar is 10 $\mu$m. (d) Relative contribution to the local fluorescence intensity of NV$^-$ and NV$^0$, obtained from fits to spectra of single NV$^-$ or NV$^0$. 

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**References**


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position relative to the Fermi level. The diamond is modeled in contact with an electrolyte, accounting for the adsorption of a water layer to the hydrophobic surface. A gate voltage $U_G$ is applied between the diamond and an external reference electrode in the electrolyte such that the hole concentration at the surface equals the experimentally determined value for measurements in air. We use the Dirichlet boundary condition $\phi(\infty) = U_G$ for the electrostatic potential in the bulk electrolyte and the Neumann boundary condition $\partial \phi / \partial x = 0$ (vanishing electric field) deep in the diamond. A bulk nitrogen concentration of $[N] = 5$ ppb is chosen, corresponding to the experimental samples. The $n$-type substitutional nitrogen is modeled with an ionization energy for N of 1.7 eV.\(^{21}\) As the diamond surface is positioned at 0 nm. (a) Density profiles for 3 doses. The solid symbols correspond to the data from (a).

Figure 4(a) shows the density of negatively charged NVs for a Gaussian implantation profile at depths (center position) of 5 nm (3.6 keV), 10 nm (7.1 keV), and 15 nm (10.7 keV) for an implantation dose of $1 \times 10^{13}$ cm$^{-2}$. It can be seen that, at an implantation depth of 5 nm, almost no NV centers are negatively charged. At a depth of 10 nm already around 37\% of the NVs are negatively charged. The rest of the nitrogen vacancies are either neutral or positively charged. The simulations show that the nitrogen vacancies are negatively charged and the brightness in the fluorescence signal of the NV$^-$ is set to 2.58 eV below the conduction-band minimum.\(^{23}\)

In conclusion, we have demonstrated how the surface termination can be used to control the charge state of the nitrogen-vacancy center in diamond. Compared to an oxygen-terminated surface, the fluorescence of NV$^-$ can be suppressed in a hydrogen-terminated surface due to a decharging or even positive charge of the defect. The deeper the NV centers are implanted into the crystal, the weaker we observe the effect of the surface termination to be. The surface conductivity of hydrogenated diamond can be used to explain this effect, as the accumulation of holes in the H-terminated diamond surface is not compatible with a negatively charged nitrogen vacancy. Simulations have confirmed this effect, showing how the charge state of the NV depends on the implantation energy. They furthermore reveal the effect of the implantation dose which influences the band bending at the diamond surface, explaining the change in contrast between O- and H-terminated
diamond regions with a constant implantation energy but varying dose.

The detailed understanding of the effect of the surface termination on the fluorescence of NVs in diamond reported in this work opens the way toward the electrostatic control of the charge state of NV centers in diamond. An external gate electrode could be used to control the density of charge carriers and, thus, the band bending at the diamond surface and, by this, provide a way for the switching of single NV centers.

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